

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SEPP14.001C1	APPLICATION NO. Unknown
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		APPLICANT Janne Kesala	
(USE SEVERAL SHEETS IF NECESSARY)		FILING DATE Herewith	GROUP Unknown

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
RRB	1 4,058,430	11/15/77	Suntola et al.			
RRB	2 4,389,973	06/1983	Suntola et al.			
RRB	3 5,855,680	01/05/99	Soininen et al.			

FOREIGN PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
				YES	NO	
RRB	4 WO 01/36702 A1	05/25/01	PCT			

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)	
RRB	5	M. Leskela et al., "Synthesis of oxide thin films and overlayers by atomic layer epitaxy for advanced applications," Materials Science & Engineering, Vol. B41 (1996), pages 23-29.
RRB	6	Niinisto et al., "ALD precursor chemistry: evolution and future challenges," Journal de Physique IV. Vol. 9 (1999), pages Pr8-837-Pr8-852.
RRB	7	Pierson, Handbook of Chemical Vapor Deposition, (1992), pp.87-88.
RRB	8	Tuomo Suntola, "Atomic Layer Epitaxy," Thin Solid Films, Vol 216 (1992), pages 84-89.

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EXAMINER	R. Bunc	DATE CONSIDERED	3 - 2005
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